

INFORMATION DISCLOSURE CITATION
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ATTY DOCKET NO. 2349-103US J088 Rec'd PC1/PTO SERIAL NO. 2 8 FEB 2001

APPLICANT(S)
Robert H. Detig

FILING DATE
October 12, 1999

GROUP

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
SL	4,732,831	22 Mar 88	Reisenfeld			
SL	4,879,184	7 Nov 89	Bujese			
SL	4,786,576	22 Nov 88	Bujese			
SL	T869004	16 Dec 69	M.B. Culhane			
SL	5,108,479	28 Apr 92	Hirano			
SL	5,493,369	20 Feb 96	Sypula et al			
SL	5,533,447	09 July 96	Johnson et al			
SL	5,544,582	13 Aug 96	Bocko et al			
SL	5,559,588	24 Sep 96	Larson et al			
SL	5,655,192	05 Aug 97	Denton et al			
SL	5,701,815	30 Dec 97	Bocko et al			

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER

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INFORMATION DISCLOSURE CITATION

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2349-103US JC02 Rec'd PCT/PTO 2 8 FEB 2001

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FILING DATE
October 12, 1999

GROUP

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
SL	5,817,441	06 Oct 98	Iwata et al			
SL	5,689,785	18 Nov 97	Kato et al			
SL	4,243,735	06 Jan 97	Kobale et al			
SL	5,240,798	31 Aug 93	Ehemann, Jr.			

FOREIGN PATENT DOCUMENTS

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						YES	NO

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